

August 1997

8-Channel/Differential 4-Channel, CMOS High Speed Analog Multiplexer

Features

- Access Time (Typical) 130ns
- Settling Time 250ns (0.1%)
- Low Leakage (Typical)
 - $I_{S(OFF)}$ 10pA
 - $I_{D(OFF)}$ 15pA
- Low Capacitance (Max)
 - $C_{S(OFF)}$ 5pF
 - $C_{D(OFF)}$ 10pF
- Off Isolation at 500kHz 45dB (Min)
- Low Charge Injection Error 25mV
- Single Ended to Differential Selectable (SDS)
- Logic Level Selectable (LLS)

Applications

- Data Acquisition Systems
- Precision Instrumentation
- Industrial Control

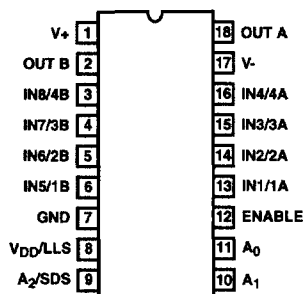
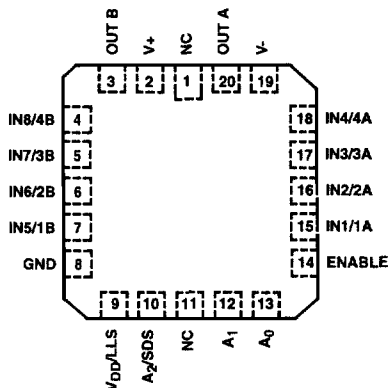
Description

The HI-518 is a monolithic, dielectrically isolated, high speed, high performance CMOS analog multiplexer. It offers unique built-in channel selection decoding plus an inhibit input for disabling all channels. The dual function of address input A_2 enables the HI-518 to be user programmed either as a single ended 8-Channel multiplexer by connecting 'Out A' to 'Out B' and using A_2 as a digital address input, or as a 4-Channel differential multiplexer by connecting A_2 to the V- supply. The substrate leakages and parasitic capacitances are reduced substantially by using the Harris Dielectric Isolation process to achieve optimum performance in both high and low level signal applications. The low output leakage current ($I_{DOFF} < 100pA$ at 25°C) and fast settling ($t_{SETTLE} = 800ns$ to 0.01%) characteristics of the device make it an ideal choice for high speed data acquisition systems, precision instrumentation, and industrial process control.

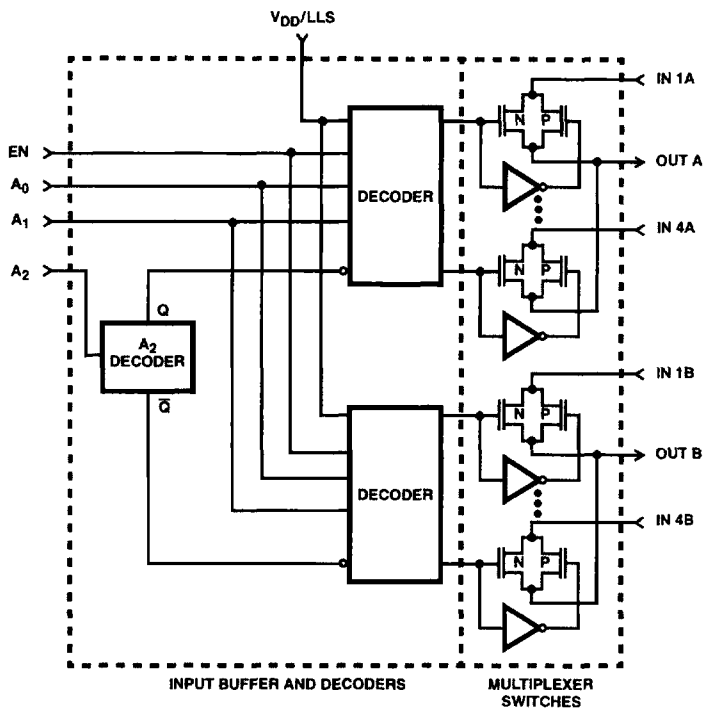
Ordering Information

PART NUMBER	TEMP. RANGE (°C)	PACKAGE	PKG. NO.
HI3-0518-5	0 to 75	18 Ld PDIP	E18.3
HI1-0518-5	0 to 75	18 Ld CERDIP	F18.3
HI1-0518-2	-55 to 125	18 Ld CERDIP	F18.3
HI1-0518-8	-55 to 125	18 Ld CERDIP	F18.3
HI4P0518-5	0 to 75	20 Ld PLCC	N20.35
HI4-0518-8	-55 to 125	20 Ld CLCC	J20.A

Pinouts

 HI-518 (CERDIP, PDIP)
TOP VIEW

 HI-518 (CLCC, PLCC)
TOP VIEW


Functional Block Diagram



A ₂ DECODE		
A ₂	Q	$\bar{Q}$
H	H	L
L	L	H
V-	L	L

Absolute Maximum Ratings (Note 1)

V+ to V-	33V
Analog Input Voltage	
+V _{IN}	(V+) +2V
-V _{IN}	(V-) -2V
Digital Input Voltage	
TTL Levels Selected (V _{DD} /LLS Pin = GND or Open)	
+V _A	+6V
-V _A	-6V
+A ₂ /SDS	(V+) +2V
-A ₂ /SDS	(V-) -2V
CMOS Levels Selected (V _{DD} /LLS Pin = V _{DD})	
+V _A	(V+) +2V
-V _A	(V-) -2V

Thermal Information

Thermal Resistance (Typical, Note 1)	θ_{JA} (°C/W)	θ_{JC} (°C/W)
PDIP Package	90	N/A
PLCC Package	80	N/A
CERDIP Package	70	18
CLCC Package	65	14
Maximum Junction Temperature		
CERDIP, CLCC Packages	175°C	
PDIP, PLCC, SOIC Packages	150°C	
Maximum Storage Temperature Range	-65°C to 150°C	
Maximum Lead Temperature (Soldering 10s)	300°C	
(PLCC - Lead Tips Only)		

Operating Conditions

Temperature Ranges

HI-518-2,-8	-55°C to 125°C
HI-518-5	0°C to 75°C

CAUTION: Stresses above those listed in "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress only rating and operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied.

NOTE:

- θ_{JA} is measured with the component mounted on an evaluation PC board in free air.

Electrical Specifications

Supplies = +15V, -15V; V_{AH} (Logic Level High) = +2.4V, V_{AL} (Logic Level Low) = +0.8V; V_{DD}/LLS = GND (Note 1), Unless Otherwise Specified

PARAMETER	TEST CONDITIONS	TEMP (°C)	HI-518-2, -8			HI-518-5			UNITS
			MIN	TYP	MAX	MIN	TYP	MAX	
SWITCHING CHARACTERISTICS									
Access Time, t_A		25	-	130	175	-	130	175	ns
		Full	-	-	225	-	-	225	ns
Break-Before-Make Delay, t_{OPEN}		25	10	20	-	10	20	-	ns
Enable Delay (ON), $t_{ON(EN)}$		25	-	120	175		120	175	ns
Enable Delay (OFF), $t_{OFF(EN)}$		25	-	140	175		140	175	ns
Settling Time									
0.1%		25	-	250	-	-	250	-	ns
0.01%		25	-	800	-	-	800	-	ns
Charge Injection Error	Note 4	25	-	-	25	-	-	25	mV
Off Isolation	Note 5	25	45	-	-	45	-	-	dB
Channel Input Capacitance, $C_{S(OFF)}$		25	-	-	5	-	-	5	pF
Channel Output Capacitance, $C_{D(OFF)}$		25	-	-	10	-	-	10	pF
Digital Input Capacitance, C_A		25	-	-	5	-	-	5	pF
Input to Output Capacitance, $C_{DS(OFF)}$		25	-	0.02		-	0.02	-	pF
DIGITAL INPUT CHARACTERISTICS									
Input Low Threshold, V_{AL} (TTL)		Full	-	-	0.8	-	-	0.8	V
Input High Threshold, V_{AH} (TTL)		Full	2.4	-	-	2.4	-	-	V
Input Low Threshold, V_{AL} (CMOS)		Full	-	-	0.3V _{DD}	-	-	0.3V _{DD}	V
Input High Threshold, V_{AH} (CMOS)		Full	0.7V _{DD}	-	-	0.7V _{DD}	-	-	V

HI-518

Electrical Specifications Supplies = +15V, -15V; V_{AH} (Logic Level High) = +2.4V, V_{AL} (Logic Level Low) = +0.8V; $V_{DD}/LLS = GND$ (Note 1), Unless Otherwise Specified **(Continued)**

PARAMETER	TEST CONDITIONS	TEMP (°C)	HI-518-2, -8			HI-518-5			UNITS
			MIN	TYP	MAX	MIN	TYP	MAX	
Input Leakage Current, I _{AH} (High)		Full	-	-	1	-	-	1	μA
Input Leakage Current, I _{AL} (Low)		Full	-	-	20	-	-	20	μA
ANALOG CHANNEL CHARACTERISTICS									
Analog Signal Range, V _{IN}	Note 2	Full	-14		+14	-15	-	+15	V
On Resistance, r _{ON}	Note 3	25	-	480	750	-	480	750	Ω
		Full	-	-	1,000	-	-	1,000	Ω
Off Input Leakage Current, I _{S(OFF)}		25	-	0.01	-	-	0.01	-	nA
		Full	-	-	50	-	-	50	nA
Off Output Leakage Current, I _{D(OFF)}		25	-	0.015	-	-	0.015	-	nA
		Full	-	-	50	-	-	50	nA
On Channel Leakage Current, I _{D(ON)}		25	-	0.015	-	-	0.015	-	nA
		Full	-	-	50	-	-	50	nA
POWER SUPPLY CHARACTERISTICS									
Power Dissipation, P _D		Full	-	-	450	-	-	540	mW
I ₊ , Current	Note 6	Full	-	-	15	-	-	18	mA
I ₋ , Current	Note 6	Full	-	-	15	-	-	18	mA

NOTES:

- V_{DD}/LLS pin = open or grounded for TTL compatibility. V_{DD}/LLS pin = V_{DD} for CMOS compatibility.
- At temperatures above 90°C, care must be taken to assure V_{IN} remains at least 1.0V below the V_{SUPPLY} for proper operation.
- $V_{IN} = \pm 10V$, $I_{OUT} = -100\mu A$.
- $V_{IN} = 0V$, $C_L = 100pF$, enable input pulse = 3V, $f = 500kHz$.
- $C_L = 40pF$, $R_L = 1K$. Due to the pin to pin capacitance between IN 8/4B and OUT B, channel 8/4B exhibits 60dB of OFF isolation under the above test conditions.
- $V_{EN} = +2.4V$.

TRUTH TABLE HI-518 Used as an 8-Channel Multiplexer or 4-Channel Differential Multiplexer

USE A_2 AS DIGITAL ADDRESS INPUT				ON CHANNEL TO	
ENABLE	A_2	A_1	A_0	OUT A	OUT B
L	X	X	X	None	None
H	L	L	L	1A	None
H	L	L	H	2A	None
H	L	H	L	3A	None
H	L	H	H	4A	None
H	H	L	L	None	1B
H	H	L	H	None	2B
H	H	H	L	None	3B
H	H	H	H	None	4B

TRUTH TABLE HI-518 Used as a Differential 4-Channel Multiplexer

A_2 CONNECT TO V-SUPPLY			ON CHANNEL TO	
ENABLE	A_1	A_0	OUT A	OUT B
L	X	X	None	None
H	L	L	1A	1B
H	L	H	2A	2B
H	H	L	3A	3B
H	H	H	4A	4B

Test Circuits and Waveforms

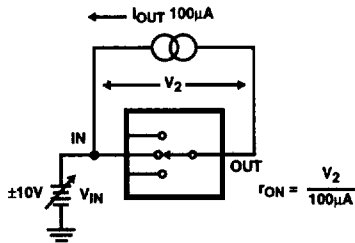


FIGURE 1. ON RESISTANCE vs INPUT SIGNAL LEVEL

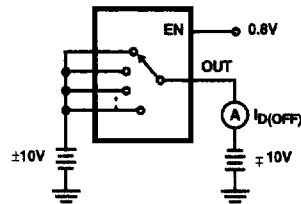


FIGURE 2. $I_{D(OFF)}$ (NOTE 1)

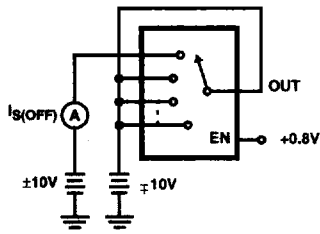


FIGURE 3. $I_{S(OFF)}$ (NOTE 1)

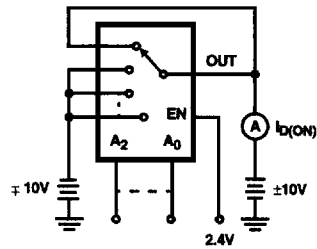


FIGURE 4. $I_{D(ON)}$ (NOTE 1)

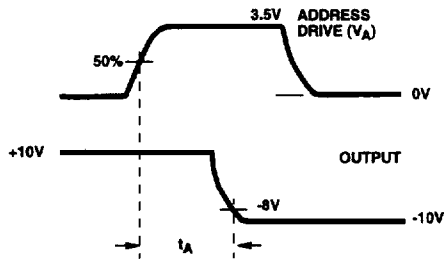


FIGURE 5A.

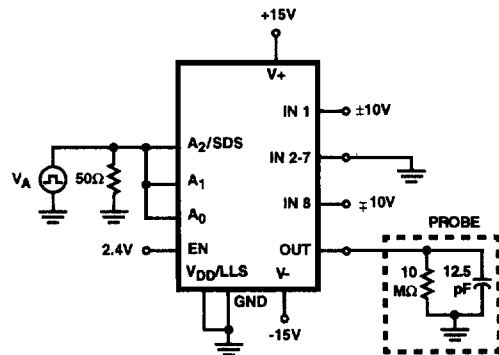


FIGURE 5B.

FIGURE 5. ACCESS TIME

NOTE:

- Two measurements per channel: $\pm 10V$ and $\mp 10V$. (Two measurements per device for $I_{D(OFF)}$ $\pm 10V$ and $\mp 10V$.)

Test Circuits and Waveforms (Continued)

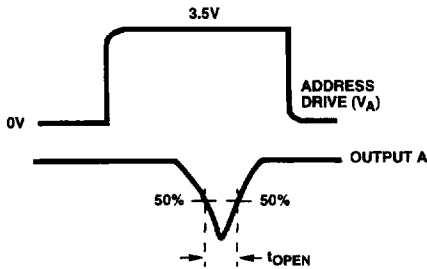


FIGURE 6A.

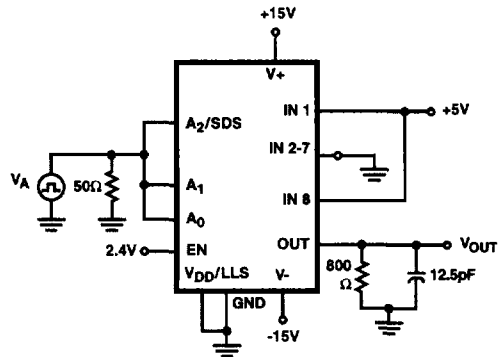
FIGURE 6. BREAK-BEFORE-MAKE DELAY (t_{OPEN})


FIGURE 6B.

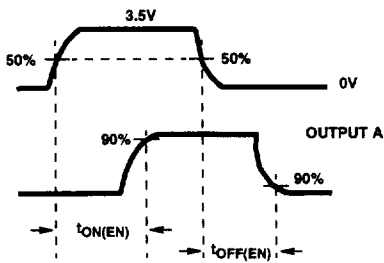


FIGURE 7A.

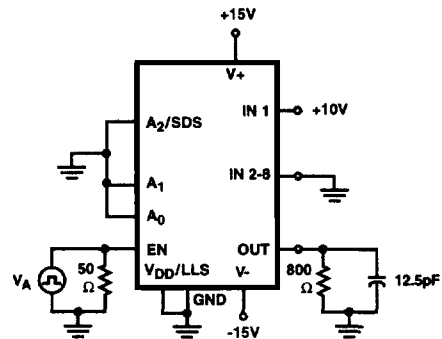
FIGURE 7. ENABLE DELAY $t_{ON(EN)}$, $t_{OFF(EN)}$


FIGURE 7B.

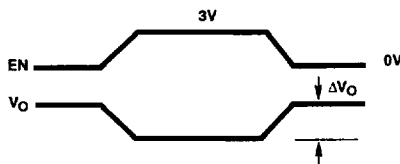


FIGURE 8A.

ΔV_O is the measured voltage error due to charge injection. The error voltage in coulombs is $Q = C_L \times \Delta V_O$.

FIGURE 8. CHARGE INJECTION TEST CIRCUIT

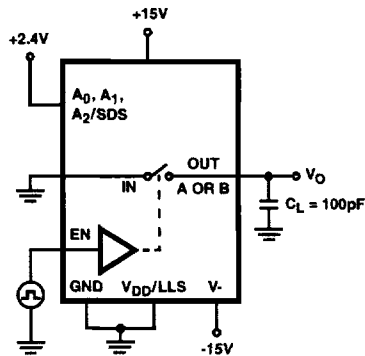


FIGURE 8B.

Die Characteristics

DIE DIMENSIONS:

89 mils x 93 mils

METALLIZATION:

Type: AlCu

Thickness: $16\text{k}\text{\AA} \pm 2\text{k}\text{\AA}$

SUBSTRATE POTENTIAL (NOTE):

$-V_{\text{SUPPLY}}$

PASSIVATION:

Type: Nitride Over Silox

Nitride Thickness: $3.5\text{k}\text{\AA} \pm 1.0\text{k}\text{\AA}$

Silox Thickness: $12\text{k}\text{\AA} \pm 2.0\text{k}\text{\AA}$

NOTE: The substrate appears resistive to the $-V_{\text{SUPPLY}}$ terminal, therefore it may be left floating (Insulating Die Mount) or it may be mounted on a conductor at $-V_{\text{SUPPLY}}$ potential.

WORST CASE CURRENT DENSITY:

$1.43 \times 10^5 \text{ A/cm}^2$

TRANSISTOR COUNT:

356

PROCESS:

CMOS-DI

Metallization Mask Layout

